



This is to certify that the Quality Management System of:

Halo Industries, Inc

3270 Scott Blvd
Santa Clara, CA 95054
United States of America
(IATF USI: 6P4PZ3)

applicable to:

Laser-Based Silicon Carbide (SiC) Wafering

has been assessed and registered by NQA, against the provisions of:

IATF 16949:2016

Clause 8.3 (product design) of IATF 16949:2016 is justifiably excluded

This registration is subject to the company maintaining a quality management system to the above standard, which will be monitored by NQA

A handwritten signature in black ink, appearing to read 'L.N. Ph'.

Managing Director

NQA Certificate No: T0216

IATF Certificate No: 0566315

First Issued: 21 Feb 2025

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